

EVG NIL Technology Day

Israel March 14, 2023

Schedule

March 14, 2023 10:00 - 16:15 hrs EVG Technology Day

Location

Daniel Herzliya Hotel, 60 Ramat Yam Street, Kefar Sava, 48905, Israel

Latest Trends in AR/VR, Silicon Photonics, Automotive and Meta Lenses

Agenda*

09:30	Registration
10:00	Welcome and Introduction Eli Dassa, NoamTech and Dr. Josef Meiler, EV Group (EVG)
10:15	NIL Market Update Andrea Kneidinger, Business Development Manager, EV Group (EVG)
10:45	Metaoptics produced but Nanoimprint Lithography and dry etching Brian Bilenberg, Founder and Executive VP, NILT
11:15	Industrial mastering of NIL Masters for AR/VR Applications and Metalenses Dr. Martin Sczyrba, TOPPAN Photomasks/ AMTC Dresden
11:45	Advances in Inkron resin technology for the NIL process Juha Pietarinen, INKRON
12:15	Lunch
13:15	NIL Process Capabilities Patrick Schuster, Process Technology Engineer, EV Group (EVG)
13:45	NIL Equipment Portfolio Anna Dudus, Product Manager, EV Group (EVG)
14:15	Advanced Dry Etching of 2D and 3D nano-structures for master mould fabrication and other applications João Ferreira, Oxford Instruments
14:45	Coffee Break
15:05	NIL Latest Developments Christine Thanner, Technology Development, EV Group (EVG)
15:35	NanoImprint Lithography for scalable silicon photonics packaging Hesham Taha, CEO and Co-Founder, Teramount
16:05	Summary and Wrap-Up

Register

For more information and to register for free:

www.EVGroup.com/events

* Preliminary Agenda